In the Claims:

This listing of claims will replace all prior versions, and listings, of claims in the application.

Listing Of Claims:

- 1. (Original) A semiconductor component, comprising:
 - a semiconductor substrate;
- a covering layer, above a hollow space, made from porous silicon material, wherein the covering layer includes a first section and a second section, a first earlier pore structure of the first section differing from a second earlier pore structure of the second section.
- 2. (Original) The semiconductor component of claim 1, wherein the semiconductor component includes a pressure sensor.
- 3. (Original) The semiconductor component of claim 1, wherein the first earlier pore structure in the first section is oriented substantially perpendicularly to a main substrate plane, and the second earlier pore structure in the second section is oriented substantially in parallel to the main substrate plane.
- 4. (Original) The semiconductor component of claim 1, wherein one of the second earlier pore structure in the second section is provided as a mesoporous structure, the second earlier pore structure in the second section is provided as a nanoporous structure, and the pore structure in the second section has a higher porosity than in the first section.
- 5. (Original) The semiconductor component of claim 1, wherein the semiconductor substrate includes silicon.
- 6. (Original) The semiconductor component of claim 1, further comprising: a diaphragm layer above the covering layer.
- 7. 10. (Canceled)